

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L9	14887	(epi\$6 or epita\$6) same (insulat\$6 or isolat\$6 or SiO2 or SiO?sub\$3 or ((Si or silicon) adj (oxide or dioxide))) same (thermal or heat\$6 or oxidat\$6 or anneal\$6 or RTA or RTP or temperature) same (interface or distort\$6 or nucle\$6 or lattice or oxygen or O2 or O?sub\$3 or oxidiz\$6 or semiconductor or substrate or wafer)	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2007/01/03 13:32
L10	9636	9 and (@ad<"20001116" or @rlad<"20001116")	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2007/01/03 13:31
L11	8238	10 and semiconductor	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2007/01/03 13:31
L12	4152	11 and ((epi\$6 or epita\$6) near20 (insulat\$6 or isolat\$6 or SiO2 or SiO?sub\$3 or ((Si or silicon) adj (oxide or dioxide))) near20 (semiconductor or substrate or wafer or interface or distort\$6 or nucle\$6 or lattice or impurity or oxygen))	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2007/01/03 13:35
L13	1978	12 and ((oxidiz\$6 or oxygen or O2 or O?sub\$3) same (heat\$6 or anneal\$6 or thermal or oxidat\$6 or RTA or RTP or temperature))	US-PGPUB; USPAT; EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2007/01/03 13:36